Special Issue

Advances in Drying Technologies—Selected Papers from the 22nd International Drying Symposium (IDS 2022)

Message from the Guest Editors

The authors of papers presented in the 22nd International Drying Symposium (IDS) are encouraged to submit their papers to *Processes* for potential publication in the Special Issue dedicated to the IDS 2022. The IDS 2022 aimed to provide the most advanced and comprehensive global forum for disseminating results and data in research, development, and applications in drying/dewatering sciences and technologies. The IDS 2022 was held on June 26–29, 2022, in Worcester, USA. https://wp.wpi.edu/ids2022/.

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You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

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